Search Notes

| Application No. | Applicant(s) | _ |
|-----------------|---------------|---|
| 10/657,451 | PARKER ET AL. | |
| Examiner | Art Unit | |
| John Juha Jr | 2872 | |

| SEARCHED | | | | | |
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| Class | Subclass | Date | Examiner | | |
| 359 | 20 | 8/6/2004 | 20 | | |
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| INTERFERENCE SEARCHED | | | | | |
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| Subclass | Date | Examiner | | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | | | |
|---|----------|------|--|--|
| | DATE | EXMR | | |
| Parent filewrapper 08/972,464 in LOC 7581 for cert. of correction | 8/6/2004 | 80 | | |
| Masks for forming the ILHM can be Type I (non-opaque) or Type II (opaque). | 8-6-04 | Ði | | |
| Non-opaque may include semi- transparent film (0.1 - 5 O.D.) film with substrantially transparent element regions therein. | 8-6-04 | 70 | | |
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